## **CLAIMS**

1. A magnetic sensor comprising:

an antiferromagnetic layer;

a first ferromagnetic layer disposed over the antiferromagnetic layer, the first ferromagnetic layer having a magnetization that is pinned by the antiferromagnetic layer;

a second ferromagnetic layer disposed over the first ferromagnetic layer, the second ferromagnetic layer having a magnetization that rotates due to an applied magnetic field;

a third ferromagnetic layer disposed adjacent to an end of the second ferromagnetic layer, the third ferromagnetic layer having a primarily in-plane magnetization providing a magnetic field to stabilize the end of the second ferromagnetic layer;

an amorphous, metallic, nonmagnetic underlayer disposed adjacent to the antiferromagnetic layer; and

a crystalline seed layer disposed between the underlayer and the third ferromagnetic layer, the seed layer having a crystalline structure that promotes the inplane magnetization of the third ferromagnetic layer.

- 2. The sensor of claim 1, wherein the underlayer isolates the third ferromagnetic layer from the crystalline structure of the antiferromagnetic layer.
- 3. The sensor of claim 1, wherein the underlayer includes gallium or tantalum.
- 4. The sensor of claim 1, wherein the underlayer includes elements X and Y, wherein X is selected from the group consisting of nickel, cobalt, iron, copper or aluminum, and Y is selected from the group consisting of niobium, phosphorous, zirconium, hafnium, tantalum, gallium, terbium, bismuth or dysprosium.

- 5. The sensor of claim 1, wherein the underlayer includes nickel-niobium.
- 6. The sensor of claim 1, wherein the seed layer includes chromium.
- 7. The sensor of claim 1, wherein the seed layer is a chromium alloy, and includes an element selected from the group consisting of titanium, vanadium, molybdenum, manganese or tungsten.
- 8. The sensor of claim 1, wherein the seed layer has a body-centered cubic (bcc) crystalline structure.
- 9. The sensor of claim 1, wherein the seed layer has a B2 crystalline structure.
- 10. The sensor of claim 1, wherein the seed layer is made of a tungsten alloy, and includes an element selected from the group consisting of titanium, vanadium, molybdenum or chromium.
- 11. The sensor of claim 1, wherein the seed layer includes tungsten.
- 12. The sensor of claim 1, wherein the seed layer includes an atomic concentration of chromium that is between fifty percent and ninety-five percent.
- 13. The sensor of claim 1, wherein the seed layer has a crystalline structure that is approximately lattice matched with that of the third ferromagnetic layer.
- 14. The sensor of claim 1, wherein the seed layer includes nickel-aluminum.
- 15. The sensor of claim 1, wherein the antiferromagnetic layer includes manganese.
- 16. The sensor of claim 1, wherein the third ferromagnetic layer includes cobalt.

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17. The sensor of claim 1, wherein the antiferromagnetic layer extends more than twice as far as the free layer in a track width direction.

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18. A magnetic sensor comprising:

an antiferromagnetic layer having a crystalline structure;

- a pinned ferromagnetic layer disposed over the antiferromagnetic layer;
- a free ferromagnetic layer disposed over the pinned ferromagnetic layer,

the free ferromagnetic layer having a magnetization that rotates due to an applied magnetic field;

a pair of magnetically hard bias layers disposed adjacent to opposite ends of the free ferromagnetic layer, the bias layers having a primarily in-plane magnetization providing a magnetic field to stabilize the ends of the free ferromagnetic layer;

a pair of amorphous, metallic, nonmagnetic underlayers disposed adjacent to the antiferromagnetic layer to isolate the crystalline structure of the antiferromagnetic layer; and

a pair of crystalline seed layers, each of the seed layers disposed between one of the underlayers and one of the bias layers to promote the in-plane magnetization of the bias layers.

- 19. The sensor of claim 18, wherein the underlayers include nickel-niobium.
- 20. The sensor of claim 18, wherein the underlayers include gallium or tantalum.
- 21. The sensor of claim 18, wherein the underlayer includes elements X and Y, wherein X is selected from the group consisting of nickel, cobalt, iron, copper or aluminum, and Y is selected from the group consisting of niobium, phosphorous, zirconium, hafnium, tantalum, gallium, terbium, bismuth or dysprosium.
- 22. The sensor of claim 18, wherein the seed layer includes chromium.
- 23. The sensor of claim 18, wherein the seed layers are made of a chromium alloy, and include an element selected from the group consisting of titanium, vanadium, molybdenum, manganese or tungsten.

- 24. The sensor of claim 18, wherein the seed layers are made of a tungsten alloy, and include an element selected from the group consisting of titanium, vanadium, molybdenum or chromium.
- 25. The sensor of claim 18, wherein the seed layers include tungsten.
- 26. The sensor of claim 18, wherein the seed layers include a body-centered-cubic (bcc) crystalline structure.
- 27. The sensor of claim 18, wherein the seed layers include a B2 crystalline structure.
- 28. The sensor of claim 18, wherein the seed layers include an atomic concentration of chromium that is between fifty percent and ninety-five percent.
- 29. The sensor of claim 18, wherein the seed layers have a crystalline structure that is approximately lattice matched with that of the bias layers.
- 30. The sensor of claim 18, wherein the seed layer includes nickel-aluminum.
- 31. The sensor of claim 18, wherein the antiferromagnetic layer includes manganese.
- 32. The sensor of claim 18, wherein the bias layers include cobalt.
- 33. The sensor of claim 18, wherein the antiferromagnetic layer extends more than twice as far as the free layer in a track width direction.

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34. A magnetic sensor comprising:

an antiferromagnetic layer having a crystalline structure;

- a pinned ferromagnetic layer disposed over the antiferromagnetic layer;
- a free ferromagnetic layer disposed over the pinned ferromagnetic layer, the free ferromagnetic layer having a magnetization that rotates due to an applied magnetic field;

a pair of amorphous, metallic, nonmagnetic underlayers disposed adjacent to the antiferromagnetic layer to isolate the crystalline structure of the antiferromagnetic layer;

a pair of crystalline seed layers, each of the seed layers disposed over one of the underlayers; and

a pair of magnetically hard bias layers disposed adjacent to opposite ends of the free ferromagnetic layer, each of the bias layers grown on one of the seed layers to have a primarily in-plane magnetization providing a magnetic field to stabilize the ends of the free ferromagnetic layer.

- 35. The sensor of claim 34, wherein the underlayers include nickel-niobium.
- 36. The sensor of claim 34, wherein the underlayers include gallium or tantalum.
- 37. The sensor of claim 34, wherein the underlayer includes elements X and Y, wherein X is selected from the group consisting of nickel, cobalt, iron, copper or aluminum, and Y is selected from the group consisting of niobium, phosphorous, zirconium, hafnium, tantalum, gallium, terbium, bismuth or dysprosium.
- 38. The sensor of claim 34, wherein the seed layers are made of a chromium alloy, and include an element selected from the group consisting of titanium, vanadium, molybdenum, manganese or tungsten.
- 39. The sensor of claim 34, wherein the seed layers are made of a tungsten.

- 40. The sensor of claim 34, wherein the seed layers are made of a tungsten alloy, and include an element selected from the group consisting of titanium, vanadium, molybdenum or chromium.
- 41. The sensor of claim 34, wherein the seed layers include a body-centered-cubic (bcc) crystalline structure.
- 42. The sensor of claim 34, wherein the seed layers include a B2 crystalline structure.
- 43. The sensor of claim 34, wherein the seed layers include an atomic concentration of chromium that is between fifty percent and ninety-five percent.
- 44. The sensor of claim 34, wherein the seed layers have a crystalline structure that is not lattice matched with the that of the antiferromagnetic layer.
- 45. The sensor of claim 34, wherein the seed layer includes nickel-aluminum.
- 46. The sensor of claim 34, wherein the antiferromagnetic layer includes manganese.
- 47. The sensor of claim 34, wherein the bias layers include cobalt.
- 48. The sensor of claim 34, wherein the antiferromagnetic layer extends more than twice as far as the free layer in a track width direction.